

(19) World Intellectual Property Organization
International Bureau



(43) International Publication Date
6 June 2002 (06.06.2002)

PCT

(10) International Publication Number
WO 02/44674 A1

(51) International Patent Classification⁷: G01J 3/443, 3/00

(21) International Application Number: PCT/US01/43164

(22) International Filing Date:
28 November 2001 (28.11.2001)

(25) Filing Language: English

(26) Publication Language: English

(30) Priority Data:
60/253,139 28 November 2000 (28.11.2000) US

(71) Applicant (for all designated States except US): **TOKYO ELECTRON LIMITED** [JP/JP]; TBS Broadcast Center, 3-6, Akasaka 5-chome, Minato-ku, Tokyo 107-8481 (JP).

(72) Inventor; and

(75) Inventor/Applicant (for US only): **MITROVIC, Andrej**, S. [YU/US]; 14435 S. 48th Street #1203, Phoenix, AZ 85044 (US).

(74) Agent: **CASEY, Michael, R.**; Oblon, Spivak, McClelland, Maier & Neustadt, P.C., 4th Floor, 1755 Jefferson Davis Highway, Arlington, VA 22202 (US).

(81) Designated States (*national*): AE, AG, AL, AM, AT, AU, AZ, BA, BB, BG, BR, BY, BZ, CA, CH, CN, CO, CR, CU, CZ, DE, DK, DM, DZ, EC, EE, ES, FI, GB, GD, GE, GH, GM, HR, HU, ID, IL, IN, IS, JP, KE, KG, KP, KR, KZ, LC, LK, LR, LS, LT, LU, LV, MA, MD, MG, MK, MN, MW, MX, MZ, NO, NZ, OM, PH, PL, PT, RO, RU, SD, SE, SG, SI, SK, SL, TJ, TM, TR, TT, TZ, UA, UG, US, UZ, VN, YU, ZA, ZM, ZW.

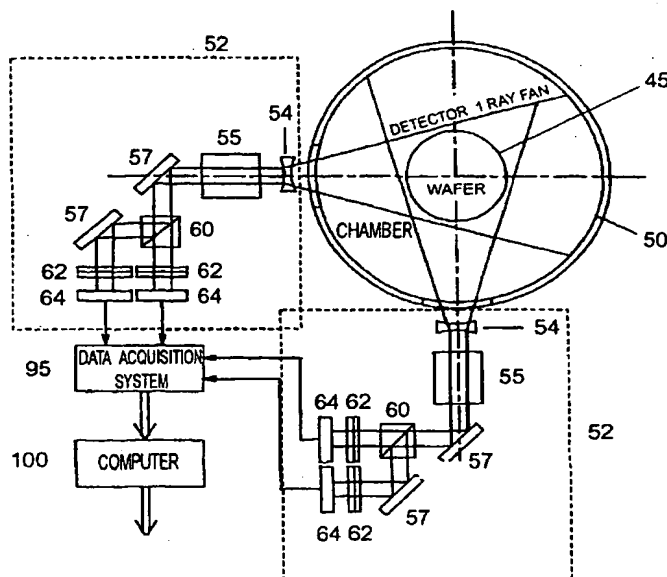
(84) Designated States (*regional*): ARIPO patent (GH, GM, KE, LS, MW, MZ, SD, SL, SZ, TZ, UG, ZM, ZW), Eurasian patent (AM, AZ, BY, KG, KZ, MD, RU, TJ, TM), European patent (AT, BE, CH, CY, DE, DK, ES, FI, FR, GB, GR, IE, IT, LU, MC, NL, PT, SE, TR), OAPI patent (BF, BJ, CF, CG, CI, CM, GA, GN, GQ, GW, ML, MR, NE, SN, TD, TG).

Published:

— with international search report

[Continued on next page]

(54) Title: METHOD AND APPARATUS FOR 2-D SPATIALLY RESOLVED OPTICAL EMISSION AND ABSORPTION SPECTROSCOPY



(57) Abstract: A multi-point detection method and system for analyzing a composition within an examination area. The system simultaneously acquires multi-dimensional distributions (e.g., two- or three-dimensional distributions) of plasma optical emissions at at least two wavelengths. Such diagnostics are useful for real-time spatially-resolved measurements of plasma electron temperature distributions and/or chemical species concentrations within a plasma processing chamber (50). Generally, the system analyzes/diagnoses the measurement of line-of-sight light emission or absorption in the plasma.

WO 02/44674 A1



— before the expiration of the time limit for amending the claims and to be republished in the event of receipt of amendments

For two-letter codes and other abbreviations, refer to the "Guidance Notes on Codes and Abbreviations" appearing at the beginning of each regular issue of the PCT Gazette.

Method And Apparatus For 2-D Spatially Resolved Optical Emission And Absorption Spectroscopy

BACKGROUND OF THE INVENTION

Field of the Invention

The present invention is directed to a method and apparatus for resolving optical emissions and absorptions, and more particularly to a method and apparatus for resolving optical emissions and absorptions in at least two dimensions.

Discussion of the Background

Recently, the use of optical diagnostics in plasma processing tools has seen a significant increase. Optical diagnostics provide the benefits of real-time signal acquisition along with being inherently non-intrusive. Known systems using optical diagnostics, such as optical emission spectroscopy, acquire signals from only a single line of sight in space at a time, typically via an optical fiber feed. At one end, light emitted from the plasma passes through a small aperture (or iris) located outside an optical vacuum window and it is focussed onto one end of the optical fiber via a focusing lens. The opposite end of the optical fiber is generally optically connected to the input of a spectrometer, wherein the light spectrum may be dispersed via a grating and the incremental wavelength spectrum recorded using a photo-detector. In such a system, acquiring a signal from another line of sight in space requires repositioning of the optical system, meaning that the measurement at the next point in space is not done at the same time as for the previous line(s) of sight.

Other known optical systems use multiple fixed optical fiber feeds. The use of multiple feeds allows the estimation of the variation, at the same instant of time, of the measured property within some region of the plasma, but such systems do not support full multi-dimensional distributions of measured plasma properties since they suffer from the "one optical fiber channel per measurement line of sight" limitation. Moreover, such systems also suffer from the fact that the optical emission or absorption they intend to measure is, in actuality, the integrated light emitted or absorbed along the line of sight which falls within the field of view of the optical apparatus.

One method and device for detecting the end point of a plasma process is disclosed in U.S. Patent No. 5,980,767 (hereinafter "the '767 patent"), assigned to the assignee of the

present invention. Figure 1 of the '767 patent is reproduced as Figure 1 of the present application. In that figure, a single detector 22 is used to analyze the condition of the plasma.

SUMMARY OF THE INVENTION

It is an object of the present invention to provide a multi-point detection method and system for analyzing a composition within an examination area. This object, and other advantages of the present invention, are addressed by a system that simultaneously acquires multi-dimensional distributions (e.g., two- or three-dimensional distributions) of plasma optical emissions at at least two wavelengths. Such diagnostics are useful for real-time spatially-resolved measurements of plasma electron temperature distributions and/or chemical species concentrations within a plasma processing chamber. Generally, the system analyzes/diagnoses the measurement of line-of-sight light emission or absorption in the plasma.

BRIEF DESCRIPTION OF THE DRAWINGS

A more complete appreciation of the invention and many of the attendant advantages thereof will be readily obtained as the same becomes better understood by reference to the following detailed description when considered in connection with the accompanying drawings, wherein:

Figure 1 is a schematic illustration of an optical end point detector system as described in a known system;

Figure 2 is a schematic illustration of a multi-detector system according to the present invention; and

Figure 3 is a schematic illustration of a computer for analyzing the sampled emission and/or absorption data according to the present invention.

DESCRIPTION OF THE PREFERRED EMBODIMENT

Referring now to the drawings, wherein like reference numerals designate identical or corresponding parts throughout the several views, Figure 2 is a schematic illustration of one embodiment of the present invention used to collect information about the processing conditions of a wafer 45 within a chamber 50. At least two detectors 52 are located circumferentially outside the processing chamber 50 such that light passes through corresponding viewports. Each detector 52 has a viewing angle Θ (e.g. the angle of the "fan

of light rays" seen by the detector). Light emitted from the chamber 50 is passed through a focusing lens 54 and an optical system 55 such that the incoming light rays are projected onto a beam splitter 60 by way of reflectors 57 (e.g., mirrors). The beam splitters 60 separate the light rays into two beams, each of which is passed through an optical filter 62 of adequate bandpass, set at the wavelength whose intensity needs to be monitored. Many different devices can be used as optical filters, e.g. colored glass and thin-film coated filters, etc. The two filtered beams are then sent onto a line-CCD device array 64, which is used to measure their light intensities. The optical system is designed in such a way that each pixel readout on the line-CCD corresponds to the light intensity at the desired wavelength of an incoming light ray on the detector, one of many rays in the "ray fan". Acquisition of light intensities on all CCD arrays, for all wavelengths and in all detectors can be made simultaneous with appropriate trigger/electronic shutter circuitry. Those intensities are passed to a data acquisition system 95, which passes the acquired data to a computer 100. (In an alternate embodiment, data can be provided to the computer 100 directly from the CCDs 64.)

In general, with a minimum of two detectors, and once a set of intensity profiles has been read from all CCDs, a numerical procedure called "tomographic inversion" (also known as "Abel inversion") can be used to recover the full two-dimensional distributions of light emission, at the two wavelengths, in a region of the plasma where the "ray fans" of the set of detectors intersect. The application of tomographic inversion (or Abel inversion) to such a set of data is discussed in detail in Gabor Herman's monographs "Image Reconstruction from Projections: The Fundamentals of Computerized Tomography" and "Image Reconstruction from Projections: Implementation and Applications", and they are herein incorporated by reference in their entirety. These two-dimensional distributions can then be used to obtain plasma properties of interest. The measurements are simultaneous on all detectors, and thus a "snapshot in time" is obtained of the plasma property distribution of interest. With the use of appropriate (e.g. fast, electronically shuttering) CCDs, suitable triggering/ shutter control electronics, and large buffer memories for measurement storage, one can acquire plasma property distributions in rapid succession, which allows the study of time-evolving phenomena in the plasma, such as chemical species concentrations.

In an alternate embodiment, the system provides multi-wavelength acquisition without a speed/repetition rate penalty. Such an embodiment splits the beam into plural channels with filters and line-CCD detectors. Although acquisition can be done on two wavelengths, additional wavelengths can also be monitored. For example, by adding "n"

additional splitters and "n" additional filters (where $n \geq 1$) and by using another CCD (or another part or parts of a multi-frequency CCD), an $(n+2)$ -wavelength detector can be provided. The same software that handled the first two wavelengths would then take care of the additional n wavelengths.

Such a system can be extended to three dimensions by adding additional planes of detection (e.g., above or below the plane formed by the detector array fan shown in Figure 2). Using three dimensions, the changes in the plasma can be analyzed across volumes of the plasma.

Referring now to the drawings, wherein like reference numerals designate identical or corresponding parts throughout the several views, Figure 3 is a schematic illustration of a computer system for measuring two-dimensional distributions of light emissions. A computer 100 implements the method of the present invention, wherein the computer housing 102 houses a motherboard 104 which contains a CPU 106, memory 108 (e.g., DRAM, ROM, EPROM, EEPROM, SRAM, SDRAM, and Flash RAM), and other optional special purpose logic devices (e.g., ASICs) or configurable logic devices (e.g., GAL and reprogrammable FPGA). The computer 100 also includes plural input devices, (e.g., a keyboard 122 and mouse 124), and a display card 110 for controlling monitor 120. In addition, the computer system 100 further includes a floppy disk drive 114; other removable media devices (e.g., compact disc 119, tape, and removable magneto-optical media (not shown)); and a hard disk 112, or other fixed, high density media drives, connected using an appropriate device bus (e.g., a SCSI bus, an Enhanced IDE bus, or a Ultra DMA bus). Also connected to the same device bus or another device bus, the computer 100 may additionally include a compact disc reader 118, a compact disc reader/writer unit (not shown) or a compact disc jukebox (not shown). Although compact disc 119 is shown in a CD caddy, the compact disc 119 can be inserted directly into CD-ROM drives which do not require caddies. In addition, a printer (not shown) also provides printed listings of two-dimensional distributions of light emissions.

As stated above, the system includes at least one computer readable medium. Examples of computer readable media are compact discs 119, hard disks 112, floppy disks, tape, magneto-optical disks, PROMs (EPROM, EEPROM, Flash EPROM), DRAM, SRAM, SDRAM, etc. Stored on any one or on a combination of computer readable media, the present invention includes software for controlling both the hardware of the computer 100 and for enabling the computer 100 to interact with a human user. Such software may include, but is not limited to, device drivers, operating systems and user applications, such as

development tools. Such computer readable media further includes the computer program product of the present invention for calculating two-dimensional distributions of light emissions. The computer code devices of the present invention can be any interpreted or executable code mechanism, including but not limited to scripts, interpreters, dynamic link libraries, Java classes, and complete executable programs.

Obviously, numerous modifications and variations of the present invention are possible in light of the above teachings. It is therefore to be understood that, within the scope of the appended claims, the invention may be practiced otherwise than as specifically described herein.

CLAIMS:

1. In a plasma processing chamber for processing substrates, wherein the processing chamber includes plural optical viewports, the improvement comprising:

a first optical system for receiving a first series of light beams in a first direction;

a first detector for receiving the first series of light beams from the first optical system;

a second optical system for receiving a second series of light beams in a second direction;

a second detector for receiving the second series of light beams from the optical system; and

a calculator for calculating two-dimensional distributions of light emissions from substantially simultaneous outputs of the first and second detectors, wherein at least a portion of the first and second series of light beams pass across a common area within the plasma processing chamber.

2. The improvement as claimed in claim 1, wherein the first and second directions are substantially perpendicular.

3. The improvement as claimed in claim 1, wherein the first and second optical systems comprise at least one beam splitter.

4. The improvement as claimed in claim 1, wherein the first and second detectors comprise multi-frequency detectors.

5. The improvement as claimed in claim 1, wherein the first and second detectors comprise CCDs.

6. The improvement as claimed in claim 1, wherein the first and second optical systems comprise at least one filter interposed between the plasma processing chamber and the first and second detectors.

7. The improvement as claimed in claim 1, wherein the substrate comprises a wafer.

8. The improvement as claimed in claim 1, wherein the calculator for calculating two-dimensional distributions of light emissions comprises a computer.

1/3

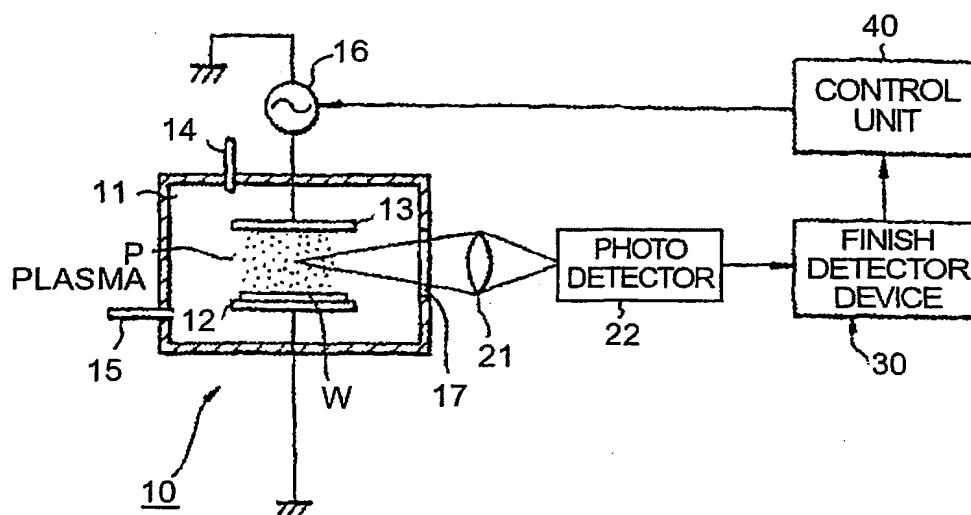


FIG. 1
(PRIOR ART)

2/3

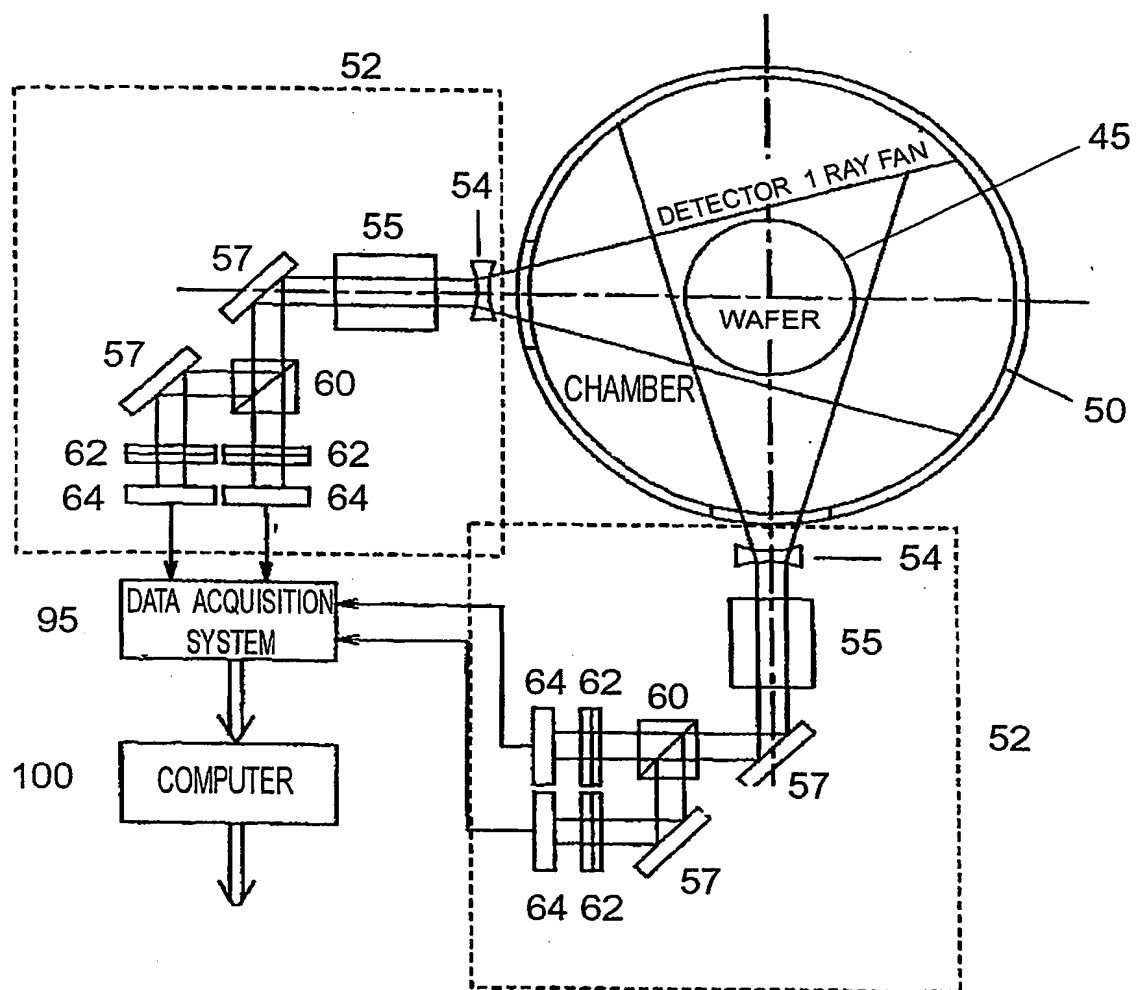


FIG. 2

3/3

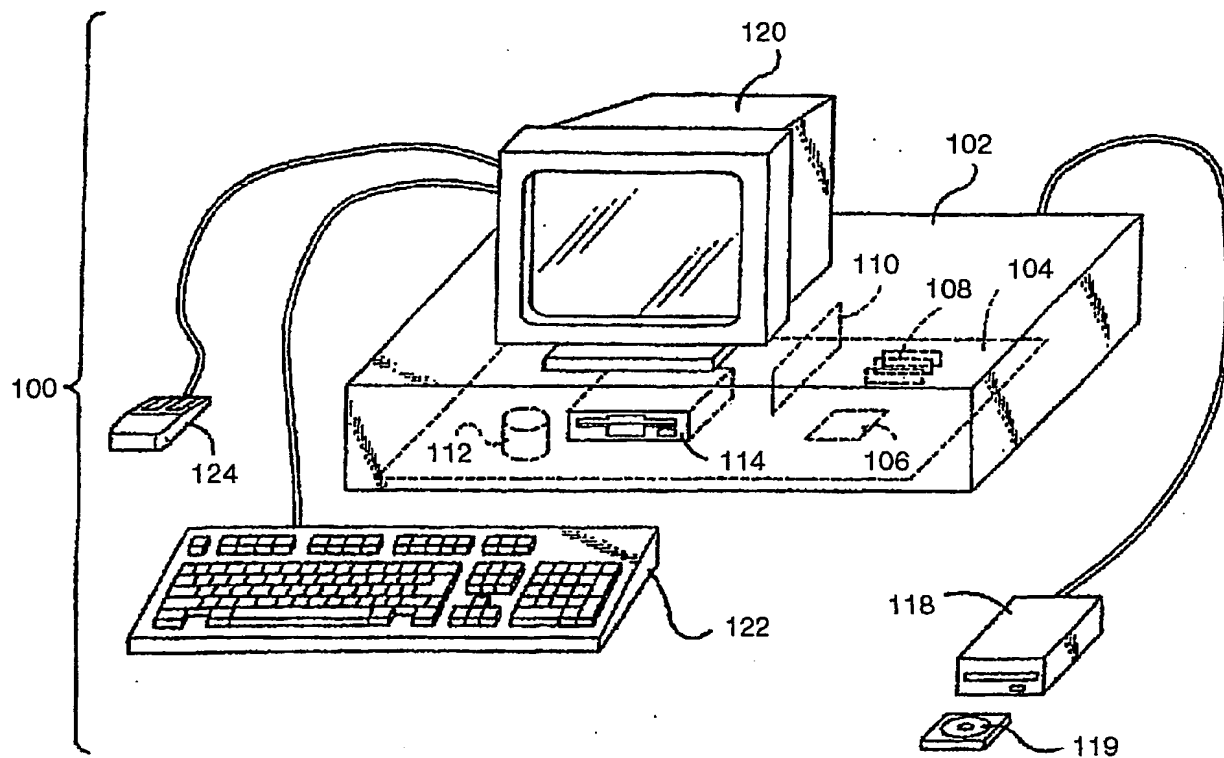


FIGURE 3

INTERNATIONAL SEARCH REPORT

International application No.

PCT/US01/43164

A. CLASSIFICATION OF SUBJECT MATTER

IPC(7) :G01J 3/443, 3/00

US CL :356/311, 300

According to International Patent Classification (IPC) or to both national classification and IPC

B. FIELDS SEARCHED

Minimum documentation searched (classification system followed by classification symbols)

U.S. : 356/311, 300, 632

Documentation searched other than minimum documentation to the extent that such documents are included in the fields searched
NONE

Electronic data base consulted during the international search (name of data base and, where practicable, search terms used)

Please See Extra Sheet.

C. DOCUMENTS CONSIDERED TO BE RELEVANT

Category*	Citation of document, with indication, where appropriate, of the relevant passages	Relevant to claim No.
X	US 5,450,205 A (SAWIN et al) 12 September 1995 (12.09.1995), Fig. 4-13, Col. 5, line 35 - Col. 24, line 25.	1-8
A	US 6,132,577 A (SMITH, JR. et al) 17 October 2000 (17.10.2000), see entire patent.	1-8
A	US 5,751,416 A (SINGH et al) 12 May 1998 (12.05.1998), see entire patent.	1-8

☐

Further documents are listed in the continuation of Box C.

☐

See patent family annex.

* Special categories of cited documents:	"T" later document published after the international filing date or priority date and not in conflict with the application but cited to understand the principle or theory underlying the invention
"A" document defining the general state of the art which is not considered to be of particular relevance	"X" document of particular relevance; the claimed invention cannot be considered novel or cannot be considered to involve an inventive step when the document is taken alone
"E" earlier document published on or after the international filing date	"Y" document of particular relevance; the claimed invention cannot be considered to involve an inventive step when the document is combined with one or more other such documents, such combination being obvious to a person skilled in the art
"L" document which may throw doubts on priority claim(s) or which is cited to establish the publication date of another citation or other special reason (as specified)	"&" document member of the same patent family
"O" document referring to an oral disclosure, use, exhibition or other means	
"P" document published prior to the international filing date but later than the priority date claimed	

Date of the actual completion of the international search

05 MARCH 2002

Date of mailing of the international search report

04 APR 2002

Name and mailing address of the ISA/US
Commissioner of Patents and Trademarks
Box PCT
Washington, D.C. 20231

Facsimile No. (703) 305-3230

Authorized officer

BROOK KEBEDE

Telephone No. (703) 306-4511

Renée Panton

INTERNATIONAL SEARCH REPORT

International application No.

PCT/US01/43164

B. FIELDS SEARCHED

Electronic data bases consulted (Name of data base and where practicable terms used):

USPAT, EPO, JPO, DERWENT, IBM, US-PGPUB

search terms: plasma chamber, light, optical, beams, computer, data, substrate or wafer, detector, CCD or charge coupled device, sensor